

1 Revision 1

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Al and Si Diffusion in Rutile

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46 **Abstract**

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48 Diffusion of Al and Si under anhydrous conditions has been measured in synthetic and natural
49 rutile. Experiments used Al₂O₃ or Al₂O₃-TiO₂ powder mixtures for Al diffusant sources, and
50 SiO₂-TiO₂ powder mixtures or quartz-rutile diffusion couples for Si. Experiments were run in air
51 in crimped Pt capsules, or in sealed silica glass ampoules with solid buffers (to buffer at NNO or
52 IW). Al profiles were measured with Nuclear Reaction Analysis (NRA) using the reaction
53 ²⁷Al(p, γ)²⁸Si. Rutherford Backscattering Spectrometry (RBS) was used to measure Si diffusion
54 profiles, with RBS also used in measurements of Al to complement NRA profiles. We determine
55 the following Arrhenius relations from these measurements:

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57 For Al diffusion parallel to c, for experiments buffered at NNO, over the temperature range

58 1100-1400°C:

59 $D_{Al} = 1.21 \times 10^{-2} \exp(-531 \pm 27 \text{ kJ mol}^{-1} / RT) \text{ m}^2\text{s}^{-1}$

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61 For Si diffusion parallel to c, for both unbuffered and NNO-buffered experiments, over the

62 temperature range 1100-1450°C:

63 $D_{Si} = 8.53 \times 10^{-13} \exp(-254 \pm 31 \text{ kJ mol}^{-1} / RT) \text{ m}^2\text{s}^{-1}$

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65 Diffusion normal to (100) is similar to diffusion normal to (001) for both Al and Si, indicating
66 little diffusional anisotropy for these elements. Diffusivities measured for synthetic and natural
67 rutile are in good agreement, indicating that these diffusion parameters can be applied in
68 evaluating diffusivities in rutile in natural systems. Diffusivities of Al and Si for experiments
69 buffered at IW are faster (by a half to three-quarters of a log unit) than those buffered at NNO.

70 Si and Al are among the slowest-diffusing species in rutile measured thus far. Diffusivities of

71 Al and Si are significantly slower than diffusion of Pb, and slower than diffusion of tetravalent

72 Zr and Hf and pentavalent Nb and Ta. These data indicate that Al compositional information will
73 be strongly retained in rutile, providing evidence for the robustness of the recently developed Al
74 in rutile thermobarometer. For example, at 900°C, Al compositional information would be
75 preserved over ~3 Gyr in the center of 250 μm radius rutile grains, but Zr compositional
76 information would be preserved for only about 300,000 years at this temperature. Al-in-rutile
77 compositions will also be much better preserved during subsolidus thermal events subsequent to
78 crystallization than those for Ti-in-quartz and Zr-in-titanite crystallization thermometers.

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Keywords: rutile, diffusion, aluminum, silicon, Rutherford Backscattering, Nuclear Reaction
Analysis, geothermometry, geobarometry

91 **Introduction**

92 Rutile, found in a variety of geological settings, can incorporate significant amounts of
93 trivalent, divalent and pentavalent cations, including several high-field strength elements, with
94 concentrations up to tens of percent (e.g., Vlassopoulos et al., 1993). The geochemical behavior
95 of these trace and minor elements in rutile can offer insight into subduction zone processes (e.g.,
96 Ewing and Müntener, 2018; Ryerson and Watson, 1987; Zack et al., 2002; Brenan et al., 1994;
97 Stalder et al, 1998; Foley et al, 2000); HFSE with multiple valence states incorporated in rutile
98 also have the potential to provide information on fO_2 conditions (e.g., Liu et al., 2014; Guo et al.,
99 2017). Since rutile tends to remain stable during sedimentary and diagenetic processes, its trace
100 element signatures can reveal information about provenance (e.g. Zack, et la., 2002; Morton et
101 al., 1999), and may be used in geospeedometry (e.g., Cruz-Uribe et al., 2014; Kohn et al., 2016).
102 The Zr-in-rutile geothermobarometer (Degeling, 2003; Zack, et al., 2004b; Watson et al. 2006;
103 Tomkins et al. 2007) has been increasingly applied in a range of studies to assess crystallization
104 temperatures and/or pressures (e.g., Mitchell and Harley, 2017; Pape et al., 2016; Ewing et al.,
105 2013; Taylor-Jones and Powell, 2015; Tual et al., 2018). Rutile is also used as a U-Pb
106 geochronometer (e.g., Corfu and Andrews, 1986; Corfu and Muir, 1989; Mezger et al., 1991;
107 1989; Schandl et al., 1990; Wong et al., 1991; Davis, 1997; Smye and Stockli, 2014).

108 In this work, we report results for Si and Al diffusion in natural and synthetic rutile, with
109 evaluation of the effects of oxygen fugacity and crystallographic orientation on diffusion. These
110 data supplement and complement earlier measurements of diffusion of trace and minor elements
111 in rutile, and may permit greater general understanding of diffusion-controlled processes in
112 rutile.

113 Most notably, recent experimental work (Hoff and Watson, 2018) has shown the potential for
114 use of Al concentrations in rutile as a geothermobarometer. Al concentrations in rutile may also
115 affect diffusion of other species, such as Cr (e.g., Sasaki et al., 1985). Taylor-Jones and Powell
116 (2015) have proposed that slow-diffusing Si in rutile may lead to the slowing of Zr diffusion,
117 resulting in higher retentivity of Zr and higher closure temperatures. However, Kohn et al.
118 (2016) have argued against the hypothesis of Zr coupling with slower-diffusing Si, asserting
119 instead that high Zr contents (and thus high Zr-in-rutile temperatures) observed in UHT rocks are
120 a consequence of the degree to which the surfaces of rutile crystals are able to maintain
121 equilibrium with matrix minerals, including zircon and baddeleyite. Despite possible
122 complexities in natural systems, measurements of Si diffusion in rutile are of value given the
123 ubiquity of silicon in geologic systems, as well as the utility of these diffusivities in
124 understanding processes such as the exsolution of zircon needles in rutile (e.g., Pepe et al, 2016).

125 Slightly reduced and doped rutiles, as semiconducting materials, have been used in a range of
126 technological applications. Al-doped rutile has been developed as an optical material (e.g, Hatta
127 et al. , 1996); Si can also be added to rutile to tailor optical properties (Gonzalez-Elipse et al,
128 2006; Demiryont, 1985). Al is a common additive to TiO₂ pigments to enhance photochemical
129 stability, and may have large effects on the conductivity of rutile and its polymorphs (Bak et al.,
130 2003), and on crystal growth and transformation kinetics (Gesenhues, 1997; Gesenhues and
131 Rentschler, 1999; Karvinen, 2003). Understanding diffusion of key dopant species in rutile can
132 assist in refining production processes and provide constraints on the long-term integrity of these
133 materials.

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136 **Experimental Procedure and Materials**

137 The majority of diffusion experiments in this study were run on synthetic rutile. The synthetic
138 rutile, from the MTI Corporation, was purchased in the form of wafers polished on one side, in
139 either (001) or (100) orientation. To explore the effects of the presence of trace and minor
140 elements on diffusion, some Si diffusion experiments were run using a natural rutile. The natural
141 rutile, from Pennsylvania, was from the same specimen as used in our earlier studies of Pb, Hf
142 and Zr diffusion in rutile (Cherniak et al., 2007a; Cherniak, 2000). Minor and trace element
143 concentrations from LA-ICPMS analyses of the rutile (based on averages of 3 or 6 point analyses
144 on synthetic and natural rutile grains, respectively) are presented in [Table 1](#). The wafers of
145 synthetic rutile were cut into square pieces, about 2 mm on a side. The natural rutile was cut
146 normal to c into slabs about 0.5 mm thick, polished with SiC papers and alumina powders down
147 to 0.3 μm , and finished with a chemical polish using colloidal silica.

148 Si diffusion experiments were conducted using quartz-rutile diffusion couples, or with powder
149 sources containing SiO_2 . The powder sources used were either dried SiO_2 powder, or a mixture
150 of TiO_2 and SiO_2 powders in 3:1 (by wt.) ratio, ground under ethanol, dried, and heated in a Pt
151 crucible for one day at 1250°C. The SiO_2 - TiO_2 powder sources worked well for experiments run
152 in air, but the buffered experiments run in sealed silica glass capsules showed significant Si-rich
153 material clinging to rutile sample surfaces following diffusion anneals, which precluded
154 successful analysis of these samples. As a consequence, only quartz-rutile diffusion couples were
155 used in buffered experiments.

156 For the Al diffusion experiments, sources of diffusant were Al_2O_3 powder, or mixtures of
157 TiO_2 and Al_2O_3 powders, in either 3:1 or 10:1 (by wt.) ratios. The TiO_2 - Al_2O_3 powder mixtures
158 were ground under ethanol, dried, and heated in Pt crucibles for one day at 1250°C. To explore

159 potential effects of coupled substitutions on Al diffusion, an experiment was run which
160 incorporated Nb into the source material. For this source, the $\text{TiO}_2\text{-Al}_2\text{O}_3$ 10:1 wt. ratio powder
161 mixture was combined with Nb_2O_5 powder in a weight ratio of 100:1.

162 For powder-source experiments, rutile crystals were surrounded by the source powders in Pt
163 capsules, and capsules crimped shut. Diffusion couples were created by placing polished faces of
164 rutile and synthetic quartz slabs in contact, tying the couple together with Pt wire, and wrapping
165 the couple in Pt mesh. For experiments run under buffered conditions, the Pt capsules or
166 diffusion couples were placed inside a silica glass ampoule with another crimped Pt capsule
167 containing the buffer material (mixtures of Ni metal and nickel oxide powders to buffer at NNO,
168 or FeO powder and Fe flakes to buffer at IW); silica glass chips were used to physically separate
169 the samples and buffer capsules inside the silica glass ampoule. The sample-buffer assemblies
170 were then sealed in the silica ampoule under vacuum.

171 All experiments were run in one-atmosphere tube furnaces with MoSi_2 heating elements, with
172 sample temperatures monitored by type S (Pt-Pt10%Rh) thermocouples with temperature
173 uncertainties of $\sim\pm 2^\circ\text{C}$. Experiments were then removed from the furnace and allowed to cool in
174 air. The rutile crystals were extracted from capsules and cleaned ultrasonically in distilled H_2O
175 and ethyl alcohol. Experimental conditions and durations for Si and Al diffusion experiments
176 are presented in [Tables 2](#) and [3](#).

177 Time-series studies were performed for both Al and Si diffusion in order to establish that the
178 measured concentration profiles are due to volume diffusion and are not a result of other
179 processes such as surface reaction that could lead to enhanced concentrations of the diffusant in
180 the near-surface region. For these time series, a set of Si diffusion experiments was performed at

181 1300°C for experiments ranging from 19 hours to one week in duration, and a set of Al diffusion
182 experiments at 1250°C for 1 to 6 days.

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184 **Nuclear Reaction Analysis (NRA) of Al**

185 The Al diffusion experiments were analyzed using nuclear reaction analysis (NRA) with the
186 reaction $^{27}\text{Al}(p,\gamma)^{28}\text{Si}$. These analyses were performed at the Ion Beam Laboratory at the
187 University at Albany, using proton beams produced by the Dyamitron accelerator. For Al
188 profiling, the 992 keV resonance of the reaction was employed, with a bismuth germanate
189 (BGO) detector used to detect gamma rays produced in the reaction (Cherniak, 1995; Cherniak
190 and Watson, 1992; Tailby et al., 2018). Energy steps of 1.0 - 0.5 keV for the incident proton
191 beam were taken near the resonance energy to profile Al at depths near the sample surface, with
192 larger energy steps (2-5 keV) at greater depths (above ~150 nm). Spectra from untreated
193 specimens of rutile were also recorded at each energy step to evaluate background levels in the
194 gamma energy region of interest, and gamma spectra of Al foil were collected as a standard to
195 convert gamma yields into Al concentrations for rutile samples. Typical detection limit for
196 analytical conditions used in this work is ~100 ppm atomic. Depth scales for the Al profiles were
197 calculated from the energy difference between the incident proton beam and the resonance
198 energy, and by the stopping power (energy loss of the protons as a function of depth in the
199 material); stopping powers used in depth calculations were determined with the software SRIM
200 (Ziegler and Biersack, 2006).

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202 **RBS analysis**

203 Si diffusion experiments were analyzed with RBS. In addition, Al diffusion experiments were
204 measured with RBS to complement the NRA analyses described above. RBS has been used as
205 the primary analytical method in many of our diffusion studies, including measurements of Pb,
206 Zr and Hf diffusion in rutile (Cherniak et al., 2007a; Cherniak, 2000). The analytical procedures
207 used here are similar, with a $^4\text{He}^+$ incident beam of 2 or 3 MeV energy used for analysis. RBS
208 spectra were converted to Si and Al concentration profiles using procedures similar to those
209 described in other work (e.g., Cherniak, 1993). Si (and Al) signals rest on those from He
210 backscattered from Ti in the sample, resulting in high backgrounds, so detection limits are on
211 order of a few tenths of an atomic percent, but Si concentrations are relatively high in the
212 samples (up to a few % atomic, at the highest temperatures of the experiments), so peaks can be
213 well-resolved from background signals. For Al, in cases where both RBS and NRA
214 measurements of samples were made (as discussed below), diffusivities agreed within
215 experimental uncertainties.

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217 **Fitting of Depth Profiles**

218 RBS and NRA depth profiles were fit with a model to determine the diffusion coefficient (D).
219 Diffusion is modeled as simple one-dimensional, concentration independent diffusion in a semi-
220 infinite medium with a source reservoir maintained at constant concentration (i.e., a
221 complementary error function solution). The rationale for the use of this model has been
222 discussed in previous publications (e.g., Cherniak and Watson, 1992). Diffusivities are evaluated
223 by plotting the inverse of the error function (i.e., $\text{erf}^{-1}((C_o - C(x,t))/C_o)$) vs. depth (x) in the
224 sample. A straight line of slope $(4Dt)^{-1/2}$ results if the data conform to a complementary error
225 function solution. C_o , the surface concentration of diffusant, is independently determined by

226 iteratively varying its value until the intercept of the line converges on zero. In [Figure 1](#), typical
227 diffusion profiles for both Al and Si are shown. The uncertainties in concentration and depth
228 from each data point (mainly derived from counting statistics and backgrounds in the former and
229 RBS detector resolution in the latter) were used to evaluate the uncertainties in the diffusivities
230 determined from the fits to the model.

231

232 **Results**

233 The results for Al diffusion are plotted in [Figure 2](#) and presented in [Table 2](#). Diffusivities
234 obtained with NRA and RBS agree within uncertainties. There is little evidence of diffusional
235 anisotropy. Al diffusion appears to have a weak negative dependence on oxygen fugacity, with
236 diffusivities under IW-buffered conditions about half a log unit higher than those under NNO-
237 buffered conditions. Samples run with the 3:1 TiO₂:Al₂O₃ source generally have higher surface
238 concentrations than samples run with the 10:1 source (typically 2-6x higher at a given
239 temperature under NNO-buffered conditions), but diffusivities agree within experimental
240 uncertainty. Surface concentrations of the diffusant also display a broad trend of increasing with
241 increasing temperature. For diffusion normal to (001), for experiments buffered at NNO, we
242 obtain an activation energy of $531 \pm 27 \text{ kJ mol}^{-1}$ and pre-exponential factor of $1.21 \times 10^{-2} \text{ m}^2 \text{ s}^{-1}$
243 ($\log D_0 = -1.92 \pm 0.92$).

244 A time series at 1250°C, conducted for Al diffusion in rutile normal to (001), with
245 experiments run for times ranging from 24 hours to more than six days ([Figure 4a](#)), results in
246 diffusivities that are consistent within experimental uncertainty, providing evidence that volume
247 diffusion, rather than other phenomena such as surface reaction, is the dominant contributor to
248 the measured diffusion profiles over this range of conditions. No anomalously-shaped profiles

249 are observed for Al (or Si) that would be suggestive of concentration-dependence of diffusion,
250 and experiments with sources containing different concentrations of diffusant yield diffusivities
251 that agree within experimental uncertainty.

252 Diffusion data for Si are plotted in [Figure 3](#) and presented in [Table 3](#). For Si diffusion
253 perpendicular to (001) in synthetic rutile under unbuffered conditions, we obtain an activation
254 energy of $275 \pm 45 \text{ kJ mol}^{-1}$ and a pre-exponential factor $4.41 \times 10^{-12} \text{ m}^2 \text{ s}^{-1}$ ($\log D_0 = -11.36 \pm$
255 1.38). There is little evidence of diffusional anisotropy when comparing diffusivities normal to
256 (100) and (001). For diffusion under NNO-buffered conditions in synthetic rutile, normal to
257 (001), an activation energy of $216 \pm 48 \text{ kJ mol}^{-1}$ and a pre-exponential factor $4.07 \times 10^{-14} \text{ m}^2 \text{ s}^{-1}$
258 ($\log D_0 = -13.39 \pm 1.62$) are obtained. A fit to both the NNO- buffered and unbuffered data
259 results in an activation energy of $254 \pm 31 \text{ kJ mol}^{-1}$ and a pre-exponential factor $8.53 \times 10^{-13} \text{ m}^2 \text{ s}^{-1}$
260 ($\log D_0 = -12.07 \pm 1.03$). Diffusivities of Si in natural rutile under NNO-buffered conditions do
261 not differ significantly from those obtained for NNO-buffered synthetic rutile, indicating that
262 differences in trace and minor element compositions between the synthetic and natural materials
263 have little effect on diffusion, a finding consistent with observations for Hf and Pb diffusion
264 (Cherniak, 2000; Cherniak et al. 2007a). Like Al, Si diffusion exhibits a negative dependence on
265 oxygen fugacity when comparing diffusivities under NNO- and IW-buffered conditions.

266 As with Al, a time series for Si diffusion in rutile normal to (001) was run, in this case at
267 1300°C for times ranging from 19 hours to a week ([Figure 4b](#)). Diffusivities are in agreement
268 within experimental uncertainties, suggesting that volume diffusion is the dominant contributor
269 to the observed Si diffusion profiles.

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272 **Comparison with diffusivities of other elements in rutile and potential diffusion**
273 **mechanisms**

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275 A summary of selected diffusion data for cations in rutile is plotted in [Figure 5](#). Si and Al are
276 among the slowest-diffusing species in rutile measured to date. Si diffuses about 6 orders of
277 magnitude slower than Ti. Diffusivities of Al and Si are significantly lower than those of
278 divalent cations, including the large divalent cations Pb and Ba (Cherniak, 2000; Nakayama and
279 Sasaki, 1963) and other trivalent cations, including Sc and Cr (Sasaki et al., 1985). Al and Si also
280 diffuse more slowly than tetravalent Zr and Hf and pentavalent Nb and Ta (Marschall et al.,
281 2013; Dohmen et al., 2018; Cherniak et al., 2007a). For example, Si diffusion is about 2 orders
282 of magnitude slower than the Zr diffusivities determined by Cherniak et al. (2007a), and about 3
283 orders of magnitude slower than Pb diffusion; Al diffusion is about 6 orders of magnitude slower
284 than Nb diffusion, and 9 orders of magnitude slower than Cr diffusion (Sasaki et al., 1985).

285 Trivalent and more highly charged cations, which may migrate via a coupled
286 interstitial/interstitialcy mechanism (Zhu et al., 2017), and divalent cations of large ionic radius
287 such as Ba (Nakayama and Sasaki, 1963) and Pb (Cherniak, 2000), do not show pronounced
288 diffusional anisotropy. This contrasts with the significant diffusional anisotropy of small divalent
289 cations, which travel interstitially through open channels in the rutile structure along the c-axis
290 (Sasaki et al., 1985), a mechanism consistent with findings from DFT calculations (Zhu et al.,
291 2017).

292 Al^{3+} predominately substitutes for Ti^{4+} on normal octahedral sites at lower pressures, but
293 higher pressures induce the incorporation of Al^{3+} into octahedral interstices of the rutile structure
294 (Escudero et al., 2012). Al solubility increases with increasing temperature (Stebbins, 2007) and

295 pressure, with 10 wt% Al₂O₃ in rutile at 1300°C and 7 GPa (Escudero et al., 2012), with
296 concentrations at 1-atm in the range of 1-2 wt% Al₂O₃ (Escudero et al., 2012; Slepetyts and
297 Vaughan, 1969); these values are broadly consistent with surface concentrations determined for
298 the lower-temperature experiments using the 10:1 TiO₂:Al₂O₃ source. For samples with up to 1
299 wt % Al₂O₃, Al is found in ordered, isolated octahedral (Ti sites), while at higher concentrations,
300 Al predominates in disordered octahedral sites, with possible contributions from both Ti sites
301 with Al neighbors and interstitials (Stebbins, 2007). The substitution of Al in Ti sites may be
302 compensated for by oxygen vacancies (Hatta et al., 1996; Islam et al., 2007); while interstitial
303 substitutions are possible, substitution on Ti lattice sites is energetically favorable. The larger
304 size of Al compared with Si, along with the potential for migrating via defect complexes to
305 preserve local charge balance, may lead to the higher activation energy for diffusion observed for
306 Al. In contrast, because of its small size compared with Ti, Si may have an off-center position in
307 the rutile lattice, and may also occupy interstitial positions (Golden et al., 2015), which could
308 contribute to the lower activation energy for Si diffusion. As with Al, Si solubilities in rutile
309 increase with increasing temperature and pressure (Ren et al., 2009), with solubilities, for
310 example, of ~1.5 wt% at 10 GPa and 1800°C, and ~5 wt% at 2000°C and 23 GPa. While it is
311 difficult to extrapolate down to lower pressure and temperature conditions, about half of our Si
312 surface concentrations fall below the former value.

313 The influence of point defect chemistry on chemical diffusion in rutile is discussed in
314 numerous publications (e.g., Nowotny et al., 2006a,b; 2012). The principal atomic defects in
315 undoped rutile are titanium interstitials and oxygen and titanium vacancies (e.g., Maruccio et al.,
316 1981; Hoshino et al., 1985; Bak et al., 2012). There are two kinetic regimes associated with the
317 diffusion-controlled equilibration kinetics of TiO₂. The first is controlled by transport of rapidly

318 moving defects (oxygen vacancies, titanium interstitials) and the second is determined by the
319 transport of titanium vacancies which diffuse much more slowly; this results in a difference in
320 diffusivities between the two regimes of about 4 orders of magnitude (Nowotny et al., 2006a;b).

321 Additional point defects will be present if altrivalent impurities reside on Ti sites in rutile.
322 Common substitutional impurities in natural rutile are the pentavalent cations Nb and Ta, ferric
323 and ferrous iron, as well as other transition elements and Al (Deer et al., 1992). Electrostatic
324 balance for pentavalent cations is commonly achieved by vacancies in cation sites, or by
325 complementary substitution of divalent or trivalent cations (such as Fe) on Ti lattice sites. The
326 pentavalent cations Ta and Nb diffuse much more rapidly than Al (Marschall et al., 2013;
327 Dohmen et al., 2018) and our results indicate that the presence of pentavalent cations as potential
328 charge compensating species appears to have little effect on Al diffusion. For divalent and
329 trivalent cations, charge compensation may be via oxygen vacancies or Ti interstitials.
330 Experimental and theoretical studies suggest that trivalent species such as Cr and Sc, and
331 tetravalent Zr are likely to diffuse via an interstitialcy mechanism that involves tetravalent
332 interstitial Ti ions (Sasaki et al., 1985; Zhu et al., 2017). The diffusion rates for these cations
333 (along with Ti self diffusion; e.g., Akse and Whitehurst, 1978) have a dependency on oxygen
334 fugacity to the negative one-fifth power ($D \propto (pO_2)^{-1/5}$), which provides supporting evidence for
335 tetravalent Ti interstitials as the controlling point defect. Recent work by Dohmen et al. (2018)
336 on diffusion of tetravalent (Zr, Hf) and pentavalent (Nb, Ta) cations in rutile has determined the
337 presence of two different diffusion mechanisms: (i) an interstitialcy mechanism involving
338 trivalent Ti on interstitial sites, and (ii) a vacancy mechanism involving Ti vacancies. The former
339 is dominant at lower fO_2 ($< QFM + 2$ log units), as well as at high temperatures (above 1350°C),

340 and has a negative dependence on fO_2 , with the latter the dominant mechanism at higher fO_2 (>
341 QFM+2) and having diffusivities largely independent of fO_2 .

342 Both Si and Al diffusivities appear broadly consistent with a negative dependence on fO_2 ,
343 suggesting an interstitialcy mechanism. In contrast to Al, activation energies for diffusion of Si
344 are similar to those for Ti. While we do not have full understanding of lattice diffusion
345 mechanisms from the results of this study, the data reported are from experiments conducted
346 under conditions of geologic relevance. These results indicate that Al and Si diffusion are not
347 greatly affected by the differing amounts of minor and trace elements present in the synthetic and
348 natural rutiles. However, it is important to note that while Al and Si concentrations in these
349 experiments approach those that could be found in mantle-derived rutile, they are much higher
350 than concentrations generally found in crustal rutile, which range up to several hundred ppm
351 (e.g., Zack et al., 2004a). The present data, given the detection limits for analysis and the
352 relatively high concentrations of Al and Si in diffusion experiments, do not preclude the
353 occurrence of differing diffusion mechanisms at lower concentrations of Al and Si.

354 The effects of pressure, and water or other hydrous species on diffusion rates are also
355 considerations in applying these experimental results. Pressure effects on diffusion in rutile have
356 not been extensively explored, but they are unlikely to be large for geologically reasonable
357 pressure ranges. There has been some investigation of the effects of hydrous species on oxygen
358 diffusion (Moore et al., 1998), which indicates that oxygen diffusion in rutile grown in the
359 presence of water, or in rutile grains reduced in such an environment, is about an order of
360 magnitude slower than in rutile reduced under anhydrous conditions, but there is little evidence
361 to date of the influence of hydrous species on cation diffusion.

362 Although the potential effects of the factors of concentration and the presence of hydrous
363 species on Al and Si diffusion are not fully resolved, we apply our diffusion data (with the
364 caveats above) in simple calculations and comparisons in the sections that follow.

365 **Si and Al diffusion in other minerals compared with rutile**

366 A summary of data for Al and Si diffusion is plotted in [Figure 6](#). As in rutile, Al diffusion in
367 Al₂O₃ has a high activation energy for diffusion, and diffusivities are comparable in magnitude
368 to those for rutile. Al diffusion is much faster in MgO, olivine, quartz, and magnetite. Si
369 diffusion in rutile is slower than quartz, MgO and labradorite, but faster than Si in zircon,
370 anorthite, and olivine, and comparable to silicate perovskite and diopside over the temperature
371 range under which experiments were conducted. However, given the differences in activation
372 energies for diffusion, Si diffusion in rutile will be faster than in most other minerals at lower
373 temperatures (below ~1000°C) with the exception of diopside and MgO.

374 B ejina and Jaoul (1997) found that diffusion parameters obtained for Si diffusion in silicates
375 conform to a linear compensation law when the activation energy for diffusion is plotted as a
376 function of the log of the pre-exponential factor. This compensation relation, using the data
377 tabulated in Bejina and Jaoul (1997), a few more recent results, including that for zircon from
378 Cherniak (2008), was described in Cherniak (2008) by the equation $E = 647.7 + 30.5 \cdot \log D_0$.
379 B ejina and Jaoul (1997) argue that compensation behavior may be explained by the ‘strain
380 energy’ model proposed in Zener (1952), in which the Gibbs free energy of diffusion is
381 considered the ‘elastic work’ required to place the defect in its excited state for migration within
382 the lattice. They note that differences in activation enthalpies among individual materials are
383 likely due to differences in the coupling of point defects that minimize the migration energy for

384 Si through the lattice, and/or the characteristic ‘extrinsicity’ of the material (based on its impurity
385 levels, non-stoichiometry, presence of aliovalent cations, and other factors).

386 Interestingly, our diffusion parameters for Si in rutile fall closely along the compensation
387 trend (Figure 7). If we interpret our findings in light of these observations, the relatively low
388 activation energy for Si diffusion in rutile may be in part attributable to the greater possibility of
389 non-stoichiometry of rutile and the potential for the coupling of point defects in ways that may
390 reduce the energies for Si migration through the mineral lattice (e.g., Bejina and Jaoul, 1997).
391 Diffusion parameters for Si in MgO (Sakaguchi et al., 1992) also fall along the compensation
392 trend. Whether this conformity to a diffusion compensation trend for Si diffusion applies to other
393 non-silicates remains unclear, but these results may be suggestive of a more generalized
394 applicability of the Meyer-Neldel Rule (diffusion compensation law) for Si diffusion. As Jones
395 (2014) has noted, when considering the case of a single diffusing species in a range of mineral
396 phases, it may be the case that those minerals with a large average activation barrier (high E_a)
397 compensate with increased frequency of attempts to diffuse (larger D_0) (e.g., Boisvert et al.,
398 1995), thus resulting in these diffusion compensation trends.

399

400 **Diffusion in mineral – element pairs used as geothermobarometers**

401 Figure 8 presents a summary of data for diffusion of mineral-element pairs employed in
402 crystallization geothermo(baro)meters. These mineral-element pairs include Zr in rutile
403 (Degeling, 2003; Zack et al., 2004b; Watson et al., 2006; Tomkins et al., 2007; Ferry and
404 Watson, 2007), Ti in zircon (Watson et al., 2006; Ferry and Watson, 2007, Watson and
405 Harrison, 2005), Ti in quartz (Wark and Watson, 2006; Thomas et al., 2010), and Zr in titanite
406 (Hayden et al., 2008), and Al in rutile (Hoff and Watson, 2018). The Al diffusion data from the

407 present work and measurements of diffusivities for the other mineral-element pairs (Cherniak,
408 2006; Cherniak et al., 2007a; b; Cherniak and Watson, 2007) can be used to evaluate the relative
409 resistance of these geothermometers to diffusional alteration when these mineral phases
410 experience subsolidus thermal events following crystallization. For comparison, we also plot our
411 data for Si diffusion.

412 Diffusion of Al in rutile is faster than Ti diffusion in zircon, but considerably slower than Ti
413 diffusion in quartz, and slower than Zr diffusion in titanite and rutile under geologically relevant
414 conditions. For example, at 800°C, Al diffusion in rutile would be about 5 orders of magnitude
415 faster than Ti diffusion in zircon, but 7 orders of magnitude slower than Ti diffusion in quartz,
416 and ~5 and 6 orders of magnitude slower than Zr diffusion in rutile and titanite, respectively.

417 At 800°C, Si would diffuse more slowly than Zr in rutile by about 2 orders of magnitude.
418 Although slower diffusivities of Si with respect to Zr in rutile are unlikely to influence
419 temperatures derived from Zr-in-rutile thermometry (Kohn et al., 2016), Si diffusion may be
420 rate-limiting for other processes, such as the exsolution of zircon needles in rutile. Also, Si is a
421 significant trace component of natural rutile whose concentration has been shown to be
422 particularly sensitive to pressure (Gaetani et al., 2008; Ren et al., 2009; Mosenfelder et al., 2010;
423 Escudero and Langenhorst, 2012). Based in part on the data of Gaetani et al. (2008), Taylor-
424 Jones and Powell (2015) proposed a preliminary equation to describe the T and P dependence of
425 Si uptake in rutile in equilibrium with quartz and zircon. A comprehensive experimental
426 calibration may emerge in the foreseeable future, which would elevate the importance of our new
427 diffusion law for Si to a new level. Taylor-Jones and Powell (2015) emphasized the potential
428 value of a high closure temperature (T_C) for Si diffusion in rutile, contrasting with the relatively
429 low T_C value for Zr diffusion (see next section).

430 The relatively low diffusivity of Al indicates that the Al-in-rutile geothermobarometer (Hoff
431 and Watson, 2018) will be resistant to diffusional resetting under a broad range of geologic
432 conditions. In the following section, we will evaluate time-temperature scenarios under which
433 these records may be preserved or compromised.

434

435 **Preservation of chemical signatures for various crystallization thermometers**

436 Using the diffusion data reported in this work, we can illustrate how well specific
437 crystallization geothermometers may preserve past temperatures with calculations that constrain
438 conditions under which resetting of Al, Si, Zr or Ti chemical signatures (and therefore
439 information about crystallization temperatures) may take place. For a simple example, we use a
440 model in which the mineral grains are spheres of radii a having an initial uniform concentration
441 of diffusant C_I , which are exposed to an external medium with diffusant concentration C_o . Based
442 on these initial and boundary conditions, a solution to the diffusion equation at the center of the
443 spheres can be derived (e.g., Crank, 1975). For circumstances when the dimensionless parameter
444 Dt/a^2 (where D is the diffusion coefficient and t is the time) has a value than or equal to 0.03, the
445 concentration at the center of the sphere will remain unchanged from the initial value. This can
446 be referred to as a "center retention" criterion. At greater values of Dt/a^2 , concentrations of
447 diffusant at the sphere's center will be is affected by the external concentration C_o . If we
448 consider an infinite cylinder geometry (better suited for many rutile grains), a similar model can
449 be applied with a as the radius of the cylinder; for this model the relevant value of the center-
450 retention parameter Dt/a^2 is ~ 0.04 .

451 In [Figure 9](#), sets of curves for Dt/a^2 for the values of these dimensionless parameters are
452 plotted, using effective diffusion radii that represent typical grain sizes for each mineral. These

453 values of radii a are 0.5 mm for quartz, 250 μm for rutile and titanite, and 50 μm for zircon. The
454 curves define the time-temperature limits under which initial Al, Si, Zr or Ti compositional
455 information will be preserved in the grain centers of each mineral, with concentrations at crystal
456 cores remaining unaltered for conditions below the curves, but affected by the surrounding
457 medium for conditions above the curves. These plots demonstrate that crystallization conditions
458 estimated from Al concentrations in rutile will be far more resistant to diffusional alteration than
459 those from the Zr-in-rutile thermometer. For example, at 900°C, Al compositional information
460 would be preserved over ~ 3 Gyr in the center of 250 μm radius rutile grains, but Zr
461 compositional information would be preserved for only about 300,000 years at this temperature.
462 Al-in-rutile compositions will also be much better preserved during subsolidus thermal events
463 subsequent to crystallization than those for Ti-in-quartz and Zr-in-titanite crystallization
464 thermometers. In general, the likelihood of preservation of Si concentrations in rutile falls
465 between that for Zr and Al.

466 The conclusions summarized above can be graphically illustrated in a manner that simulates
467 x-ray maps that could be obtained on individual rutile crystals in natural rocks. Concentration
468 contour maps are well-suited to portraying the spatial distribution (and therefore diffusion
469 progress) of elements in natural crystals, as a complement to the sometimes intuitively elusive
470 dimensionless quantity Dt/a^2 . To this end, we ran simulations of Si, Al and Zr diffusion in rutile
471 crystals with the goal of contouring the resulting concentrations in 2-D section to illustrate and
472 compare results. In this case our model crystal was a cylindrical rutile grain 200 μm in diameter
473 and 600 μm long; calculations were performed using the CYLMOD computer program written
474 by Watson et al. (2010) for the purpose of modeling diffusion in finite cylinders. The
475 concentration of the elements was held constant at the cylinder surface at an arbitrary value

476 below the initial (uniform) concentration within the cylinder. The broad objective was to
477 illustrate outcomes for the three elements that span behaviors from nearly closed (very limited
478 diffusion) to badly compromised. An isothermal heating event lasting 10 million years was used
479 for this comparison; results are shown in [Figure 10](#) as concentration contours within the rutile
480 cylinder expressed in terms of % of the initial uniform value. For the time span considered,
481 diffusion progress for Al, Si and Zr is approximately the same (and very limited) at 900, 700 and
482 500°C, respectively. The three diffusants also show similar progress (66-78% overall retention)
483 at 950, 800 and 600°C, respectively. Higher temperatures result pronounced open-system
484 behavior, as shown by the bottom row of panels in [Figure 10](#).

485 All of the preceding discussion applies to isothermal conditions. Given the availability of
486 diffusion laws for the relevant elements, the possibility of open-system behavior during both
487 prograde and retrograde metamorphism can also be readily addressed. Resetting of
488 thermobarometers during geologic cooling can be evaluated qualitatively using the well-known
489 closure-temperature equation of Dodson (1973), which returns closure temperatures for Al, Si
490 and Zr in rutile of ~1050°C, ~930°C, and ~700°C for spherical grains of 250 μm radius cooling
491 at 10°C /Myr. Similarly, there may be instances where rutile crystallizes in a metabasite at
492 relatively low temperature and is subsequently heated with increasing metamorphic grade,
493 possibly resetting one or more thermobarometers. In this case it is instructive to explore both
494 center retention (defined as above), and diffusive "opening", which we define as a 1% diffusive
495 loss or gain of the element of interest — i.e., incipient open-system behavior. Diffusive
496 "opening" and center retention during linear heating of spherical grains are readily evaluated
497 using the generalized expression of Watson and Cherniak (2013):

$$T_{rt\%} = \frac{0.457 \cdot (E_a / R)}{\chi_h + \log \left[\frac{E_a \cdot D_0}{R \cdot dT/dt \cdot a^2} \right]} \quad (1)$$

499 where D_0 and E_a are the Arrhenius parameters for the diffusant of interest, dT/dt is the heating
500 rate, a is the radius of the grain domain, R is the gas constant, and χ_h is a constant describing the
501 fraction of change in the amount. For a given heating trajectory, $T_{rt\%}$ is the temperature (in
502 kelvins) at which a specific fractional retention (or loss) is reached, and where the constant χ_h
503 will have a specific value depending on the amount of fractional loss. For retention levels of
504 50% and 99%, the center retention and diffusive opening criteria defined above, χ_h has values of
505 -0.785 and 2.756, respectively. In calculations, we use a linear heating rate of 10°C/Myr and plot
506 opening and center retention temperatures for Al as a function of grain radius in [Figure 11](#). For
507 comparison, we also plot conditions for diffusive opening of both Zr and Pb in rutile, using the
508 diffusion parameters of Cherniak et al. (2007a) and Cherniak (2000) respectively. This provides
509 additional illustration of the comparatively high retentivity for Al chemical signatures in rutile;
510 for example, Al would require heating to temperatures in excess of 840°C to induce a 1% change
511 in Al composition in 100µm radius rutile grains, while comparable changes in Zr and Pb
512 compositions would result when reaching temperatures of only ~420°C and ~480°C,
513 respectively.

514

515 **Implications**

516 This study has shown that both Al and Si are among the slowest-diffusing species measured in
517 rutile to date. With these slow diffusivities, the recently-developed Al-in-rutile crystallization
518 geothermobarometer (Hoff and Watson, 2018) will be a robust indicator of past temperature and
519 pressure conditions, more resistant to diffusional alteration than the Zr-in-rutile crystallization

520 thermometer. In addition, should a Si-in-rutile thermometer become more fully developed, Si
521 concentrations in rutile will likewise provide a crystallization thermometer resistant to alteration
522 by diffusion.

523
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528
529

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774 Table 1. Trace and minor element compositions of rutile
775 from LA-ICPMS analyses

Element (ppm)	Natural Rutile (PA)	Synthetic Rutile
Al	330 ± 25	26 ± 9
V	1326 ± 32	--
Cr	538 ± 24	--
Fe	3063 ± 220	8 ± 4
Ni	279 ± 26	--
Zr	113 ± 6	--
Nb	2738 ± 101	--
Hf	5.9 ± 0.3	--
Ta	119 ± 3	--
W	65 ± 3	--

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781 Table 2. Al Diffusion in Rutile

	$T(^{\circ}C)$	$time(sec)$	$D(m^2sec^{-1})$	$\log D$	+/-	buffer	C_o^{\dagger}	source*
782	<i>normal to (001):</i>							
	RuAl-11	1100	1.72x10 ⁶	3.78x10 ⁻²³	-22.42	0.41	NNO	0.69 10:1
	RuAl-7	1151	9.43x10 ⁵	3.93x10 ⁻²²	-21.41	0.17	NNO	3.91 3:1
	RuAl-10	1150	7.83x10 ⁵	3.84x10 ⁻²²	-21.42	0.34	NNO	0.73 10:1
	RuAl-24	1150	3.51x10 ⁵	1.99x10 ⁻²¹	-20.70	0.16	IW	3.81 10:1
	RuAl-1	1200	4.28x10 ⁵	1.64x10 ⁻²¹	-20.78	0.18	UB	6.89 3:1
	RuAl-2	1200	2.59x10 ⁵	2.26x10 ⁻²¹	-20.65	0.16	NNO	5.71 3:1
	RuAl-9	1200	4.18x10 ⁵	1.76x10 ⁻²¹	-20.75	0.25	NNO	1.05 10:1
	RuAl-20	1200	2.59x10 ⁵	1.30x10 ⁻²¹	-20.89	0.17	NNO	5.64 10:1 + Nb
	RuAl-3	1250	1.67x10 ⁵	7.38x10 ⁻²¹	-20.13	0.15	NNO	7.65 3:1
	RuAl-16	1250	8.64x10 ⁴	1.02x10 ⁻²⁰	-19.99	0.14	NNO	3.81 10:1
	RuAl-12	1250	1.66x10 ⁵	8.01x10 ⁻²¹	-20.10	0.11	NNO	4.60 10:1
	RuAl-15	1250	5.45x10 ⁵	6.48x10 ⁻²¹	-20.19	0.13	NNO	1.42 10:1
	RuAl-19	1250	2.02x10 ⁵	9.33x10 ⁻²¹	-20.03	0.10	UB	2.02 Al ₂ O ₃
	RuAl-23	1250	5.45x10 ⁵	2.03x10 ⁻²⁰	-19.69	0.08	IW	5.16 10:1
	RuAl-4	1300	6.84x10 ⁴	2.89x10 ⁻²⁰	-19.54	0.13	NNO	9.97 3:1
	RuAl-13	1300	9.24x10 ⁴	2.87x10 ⁻²⁰	-19.54	0.12	NNO	3.70 10:1
	RuAl-6	1350	5.04x10 ⁴	7.12x10 ⁻²⁰	-19.15	0.16	NNO	7.65 3:1
	RuAl-14	1350	5.40x10 ⁴	6.18x10 ⁻²⁰	-19.21	0.12	NNO	4.05 10:1
	RuAl-22	1350	6.12x10 ⁴	2.22x10 ⁻¹⁹	-18.65	0.08	IW	7.13 10:1
	RuAl-5	1400	1.80x10 ⁴	5.50x10 ⁻¹⁹	-18.26	0.26	NNO	4.50 3:1
783	<i>(100)</i>							
	RuAl-17	1200	3.35x10 ⁵	2.14x10 ⁻²¹	-20.67	0.16	NNO	1.07 10:1
	RuAl-18	1300	7.56x10 ⁴	4.89x10 ⁻²⁰	-19.31	0.23	NNO	1.14 10:1

784 * 3:1 - 3:1 ratio (by wt.) TiO₂: Al₂O₃; 10:1 - 10:1 ratio (by wt.) TiO₂:Al₂O₃

785 † surface concentration in at. percent

786

787 Table 3. Si Diffusion in Rutile

	$T(^{\circ}C)$	$time(sec)$	$D(m^2sec^{-1})$	$\log D$	+/-	buffer	C_o^{\dagger}	source	
788	<i>normal to (001):</i>								
	RuSi-38	1100	9.49×10^5	2.02×10^{-22}	-21.69	0.40	NNO	0.63	diff couple
	RuSi-11	1149	9.50×10^5	5.50×10^{-22}	-21.26	0.34	UB	1.89	TiO ₂ :SiO ₂
	RuSi-34	1151	5.11×10^5	6.76×10^{-22}	-21.17	0.39	NNO	0.99	diff couple
	RuSi-42	1150	3.51×10^5	2.92×10^{-21}	-20.53	0.17	IW	3.81	diff couple
	RuSi-1	1200	3.53×10^5	6.39×10^{-22}	-21.19	0.35	UB	1.09	SiO ₂
	RuSi-31	1200	2.82×10^5	1.56×10^{-21}	-20.81	0.34	UB	0.69	diff couple
	RuSi-32	1200	2.48×10^5	1.52×10^{-21}	-20.82	0.23	NNO	1.73	diff couple
	RuSi-2	1250	1.98×10^5	1.30×10^{-21}	-20.88	0.20	UB	1.74	SiO ₂
	RuSi-37	1250	2.45×10^5	9.36×10^{-22}	-21.03	0.21	NNO	4.15	diff couple
	RuSi-41	1250	2.56×10^5	1.31×10^{-20}	-19.88	0.20	IW	2.99	diff couple
	RuSi-3	1301	7.56×10^4	3.36×10^{-21}	-20.47	0.20	UB	1.66	SiO ₂
	RuSi-4	1301	6.84×10^4	3.97×10^{-21}	-20.40	0.31	UB	1.15	TiO ₂ :SiO ₂
	RuSi-20	1299	5.83×10^5	2.15×10^{-21}	-20.67	0.18	UB	3.46	TiO ₂ :SiO ₂
	RuSi-21	1299	2.54×10^5	2.43×10^{-21}	-20.61	0.18	UB	3.34	TiO ₂ :SiO ₂
	RuSi-28	1300	8.64×10^4	8.85×10^{-21}	-20.05	0.29	UB	0.94	SiO ₂
	RuSi-35	1300	8.64×10^4	2.30×10^{-21}	-20.64	0.44	NNO	2.19	diff couple
	RuSi-7	1351	5.76×10^4	8.23×10^{-21}	-20.08	0.18	UB	4.12	TiO ₂ :SiO ₂
	RuSi-36	1350	7.56×10^4	3.79×10^{-21}	-20.42	0.14	NNO	7.17	diff couple
	RuSi-40	1350	7.56×10^4	4.41×10^{-20}	-19.36	0.27	IW	1.40	diff couple
	RuSi-6	1400	1.44×10^4	1.19×10^{-20}	-19.92	0.20	UB	4.88	TiO ₂ :SiO ₂
	RuSi-39	1400	1.44×10^4	1.78×10^{-20}	-19.75	0.29	NNO	4.98	diff couple
	RuSi-8	1450	7.20×10^3	2.22×10^{-20}	-19.65	0.19	UB	8.96	TiO ₂ :SiO ₂
789	<i>normal to (100):</i>								
	RuSi-10	1200	3.46×10^5	4.80×10^{-22}	-21.32	0.29	UB	0.77	TiO ₂ :SiO ₂
	RuSi-13	1299	9.00×10^4	5.00×10^{-21}	-20.30	0.30	UB	0.64	TiO ₂ :SiO ₂
	RuSi-19	1399	5.94×10^4	1.22×10^{-20}	-19.91	0.28	UB	1.19	TiO ₂ :SiO ₂
790	<i>natural rutile, cut parallel to c:</i>								
	NRuSi-9	1150	4.28×10^5	3.26×10^{-22}	-21.49	0.46	NNO	0.95	diff couple
	NRuSi-8	1250	6.48×10^4	3.02×10^{-21}	-20.52	0.38	NNO	0.96	diff couple
	NRuSi-10	1350	1.62×10^4	1.35×10^{-20}	-19.87	0.18	NNO	4.78	diff couple

791 † surface concentration in at. percent

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795 **Captions for figures**

796 Figure 1. Example Al (a) and Si (b) diffusion profiles for rutile. The Al experiment (on synthetic
797 rutile, with diffusion normal to (001)) was run at 1400°C for 5h. Profiles from both RBS and
798 NRA, using the $^{27}\text{Al}(p,\gamma)^{28}\text{Si}$ reaction, are plotted. The Si profiles are from an experiment on
799 synthetic rutile run at 1350°C for 16h (grey symbols), and for an experiment on natural rutile run
800 for 4.5h at 1350°C (white symbols).

801

802 Figure 2. Arrhenius plot of Al diffusion data for rutile. For diffusion normal to (001), for
803 experiments buffered at NNO, we obtain an activation energy of $531 \pm 27 \text{ kJ mol}^{-1}$ and pre-
804 exponential factor of $1.21 \times 10^{-2} \text{ m}^2 \text{ s}^{-1}$ ($\log D_0 = -1.92 \pm 0.92$). There appears to be little
805 anisotropy when comparing diffusion normal to (001) and (100). Diffusion under IW-buffered
806 conditions is faster by about half a log unit.

807

808 Figure 3. Arrhenius plot of Si diffusion data for synthetic and natural rutile. For Si diffusion
809 perpendicular to (001) in synthetic rutile under unbuffered conditions, we obtain an activation
810 energy of $275 \pm 45 \text{ kJ mol}^{-1}$ and a pre-exponential factor $4.41 \times 10^{-12} \text{ m}^2 \text{ s}^{-1}$ ($\log D_0 = -11.36 \pm$
811 1.38). There is little evidence of diffusional anisotropy when comparing diffusivities normal to
812 (100) and (001). For diffusion under NNO-buffered conditions in synthetic rutile, normal to
813 (001), an activation energy of $216 \pm 48 \text{ kJ mol}^{-1}$ and a pre-exponential factor $4.07 \times 10^{-14} \text{ m}^2 \text{ s}^{-1}$
814 ($\log D_0 = -13.39 \pm 1.62$) are obtained; a fit to both the NNO- buffered and unbuffered data results
815 in an activation energy of $254 \pm 31 \text{ kJ mol}^{-1}$ and a pre-exponential factor $8.53 \times 10^{-13} \text{ m}^2 \text{ s}^{-1}$ ($\log D_0$
816 $= -12.07 \pm 1.03$). Diffusivities of Si in natural rutile under NNO-buffered conditions do not differ
817 significantly from those obtained for NNO-buffered synthetic rutile, indicating that differences in

818 trace and minor element compositions between the synthetic and natural materials have little
819 effect on diffusion. Like Al, Si diffusion exhibits a negative dependence on oxygen fugacity;
820 diffusivities under IW-buffered conditions are ~three quarters of a log unit faster than under
821 NNO-buffered conditions.

822

823 Figure 4. Time series for Al (a) and Si (b) at 1250°C and 1300°C, respectively. For both
824 elements, diffusivities are quite similar over times varying by more than a factor of 6, suggesting
825 that volume diffusion is the dominant contributor to the observed diffusion profiles.

826

827 Figure 5. Selected cation diffusion data for rutile. Sources for data: Cr, Fe - Sasaki et al. (1985);
828 Ti- Akse and Whitehurst, 1978; Nb, Ta - Marschall et al. (2013); Hf, Zr - Cherniak et al (2007);
829 Pb - Cherniak (2000); Al, Si - this study.

830

831 Figure 6. (a) Al diffusion data for selected minerals. Sources for data: quartz - Tailby et al.,
832 2018; forsterite - Zhukova et al., 2017; MgO - Van Orman et al., 2009; Al₂O₃ - LeGall et al.,
833 1994; Paladino and Kingery, 1962; magnetite - Dieckmann et al. 1978; mullite - Fielitz et al.,
834 2006. (b) Si diffusion data for selected minerals. Sources for data: quartz, anorthite, labradorite -
835 Cherniak, 2003; zircon - Cherniak, 2008; forsterite - Jaoul et al., 1981; olivine - Dohmen et al,
836 2002; MgO - Sakaguchi et al., 1992; diopside - Bějina and Jaoul, 1996; perovskite - Yamazaki et
837 al. , 2000.

838

839 Figure 7. Plot of activation energy (in kJ mol⁻¹) vs. the log of the pre-exponential factor D₀,
840 showing that Si diffusion data for silicates conform well to the linear ‘diffusion compensation’

841 relation outlined by Bejina and Jaoul (1997) and Cherniak (2008). The compensation line can be
842 described by the equation $E = 647.7 + 30.5 \cdot \log D_0$. Data plotted are from Bejina and Jaoul
843 (1997) and Cherniak (2008). Results for Si diffusion in rutile from the present study (dark
844 squares) are also plotted. These fall closely along the diffusion compensation trend, as does that
845 for Si diffusion in MgO (white square).

846

847 Figure 8. Summary of data for diffusion of mineral-element pairs employed in selected
848 crystallization geothermometers. Sources for data: Ti - zircon: Cherniak and Watson (2007); Zr
849 - rutile: Cherniak et al. (2007a); Zr- titanite; Cherniak (2006); Ti - quartz: Cherniak et al.
850 (2007b); Al - rutile: this study.

851

852 Figure 9. Curves representing time-temperature conditions for mineral-element pairs used in
853 crystallization thermometers under which Ti, Zr, Al or Si signatures at the center of grains will
854 be lost. For times and temperatures below the curves, concentrations at crystal cores will remain
855 unaffected, but will be influenced by the surrounding medium when conditions above the curves
856 apply. In calculations, diffusivities from the Arrhenius relations plotted in [Figure 8](#) are used, and
857 effective diffusion radii differing with mineral type are selected to reflect grain sizes typical for
858 each mineral: 50 μm for zircon, 0.5 mm for quartz, and 250 μm for both rutile and titanite. Rutile
859 will be considerably more retentive of Al compositions at grain centers than Zr; for example, at
860 900°C, Zr signatures would be altered in times of $\sim 300,000$ years, while Al signatures would be
861 preserved at this temperature over times on order 3 billion years.

862

863 Figure 10. Results of diffusion calculations for a cylindrical model rutile crystal 200 μm in
864 diameter and 600 μm long. The cylinder axis (dashed line) lies in the plane of the panels, which
865 are contoured to show the diffusional response of Si, Al and Zr at the temperatures indicated for
866 a holding time of 10 million years. Contours represent % retention of the original element
867 concentration at a given axial and radial location within the crystal. The contour interval is 10%;
868 the innermost contour represents 90% retention except where indicated otherwise. F is the
869 fraction of the element retained in the bulk crystal. The three temperatures modeled for each
870 element were chosen to show the transition from essentially closed-system behavior ($F > 0.9$; top
871 row) to severely compromised elemental concentrations (bottom row). See text for details.

872

873 Figure 11. Conditions for diffusive "opening" (defined as loss of 1% of the diffusant) and center
874 retention (equivalent to preservation of initial composition at grain center, but 50% loss of
875 diffusant) for Al, Pb, Si and Zr in rutile in the case of linear heating. Calculations are performed
876 using equation 1, a linear heating rate of $10^\circ\text{C}/\text{Ma}$, the appropriate values of the constant χ_h for
877 each criterion, and the diffusion parameters plotted in Figure 5. These calculations again
878 illustrate the relative robustness of Al chemical signatures in rutile.

879

Figure 1

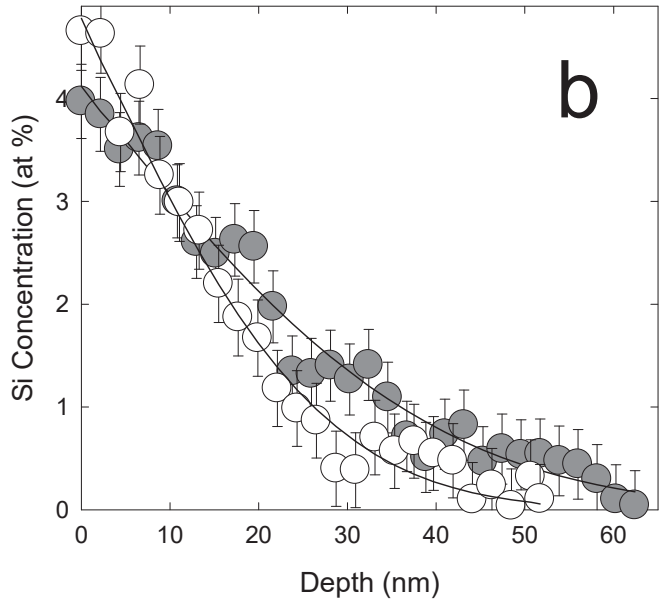
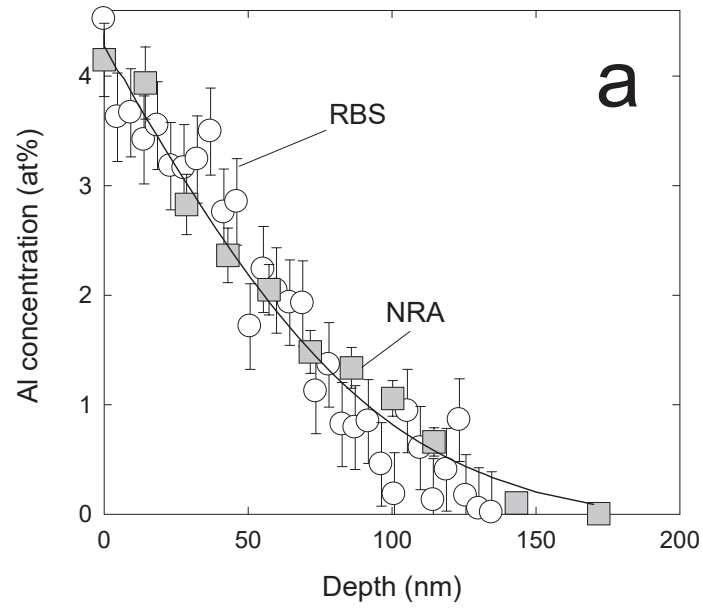


Figure 2

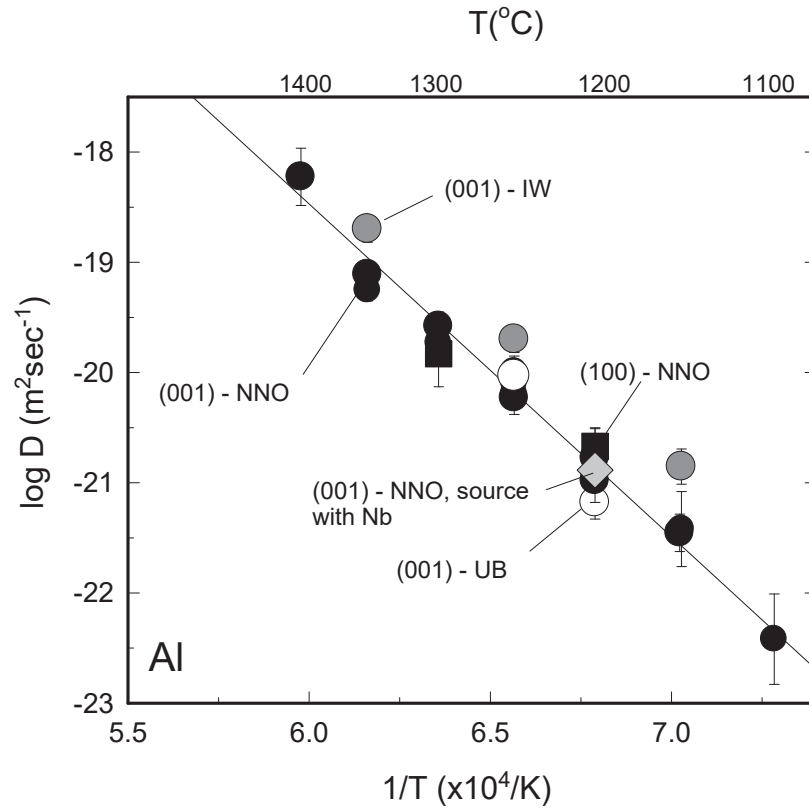


Figure 3

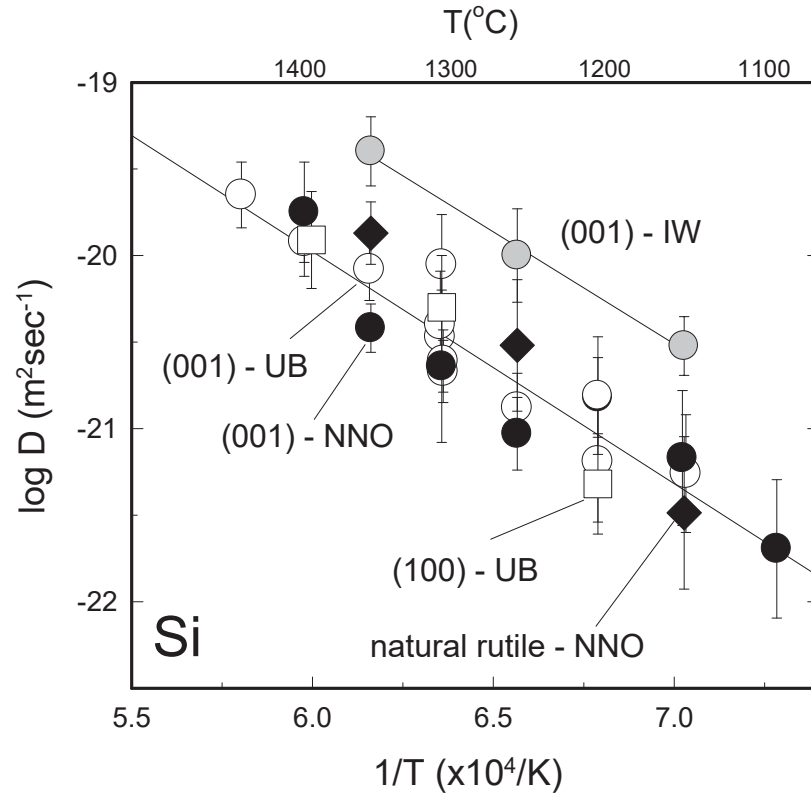


Figure 4

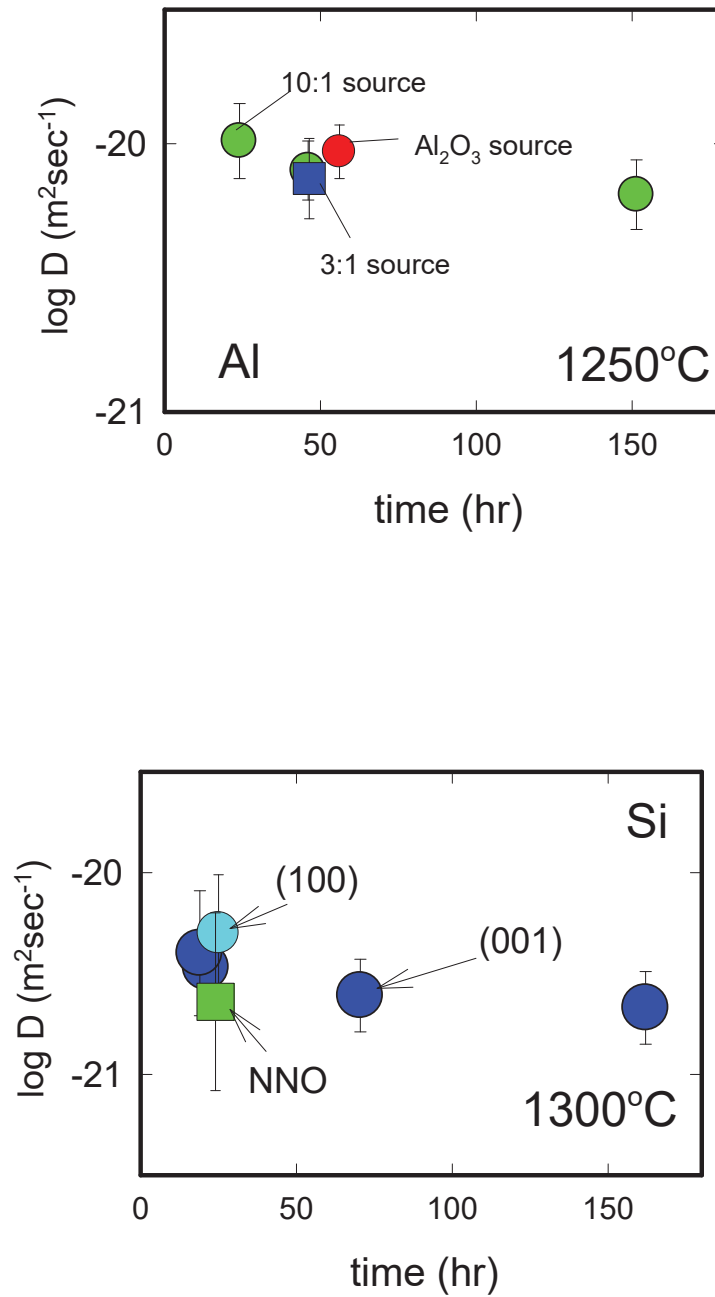


Figure 5

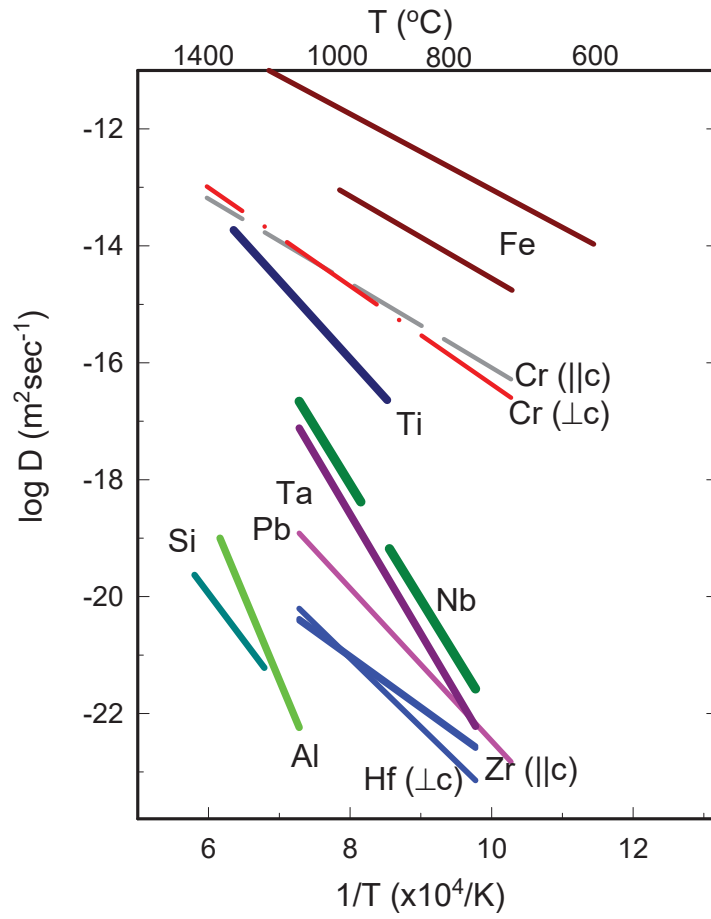


Figure 6

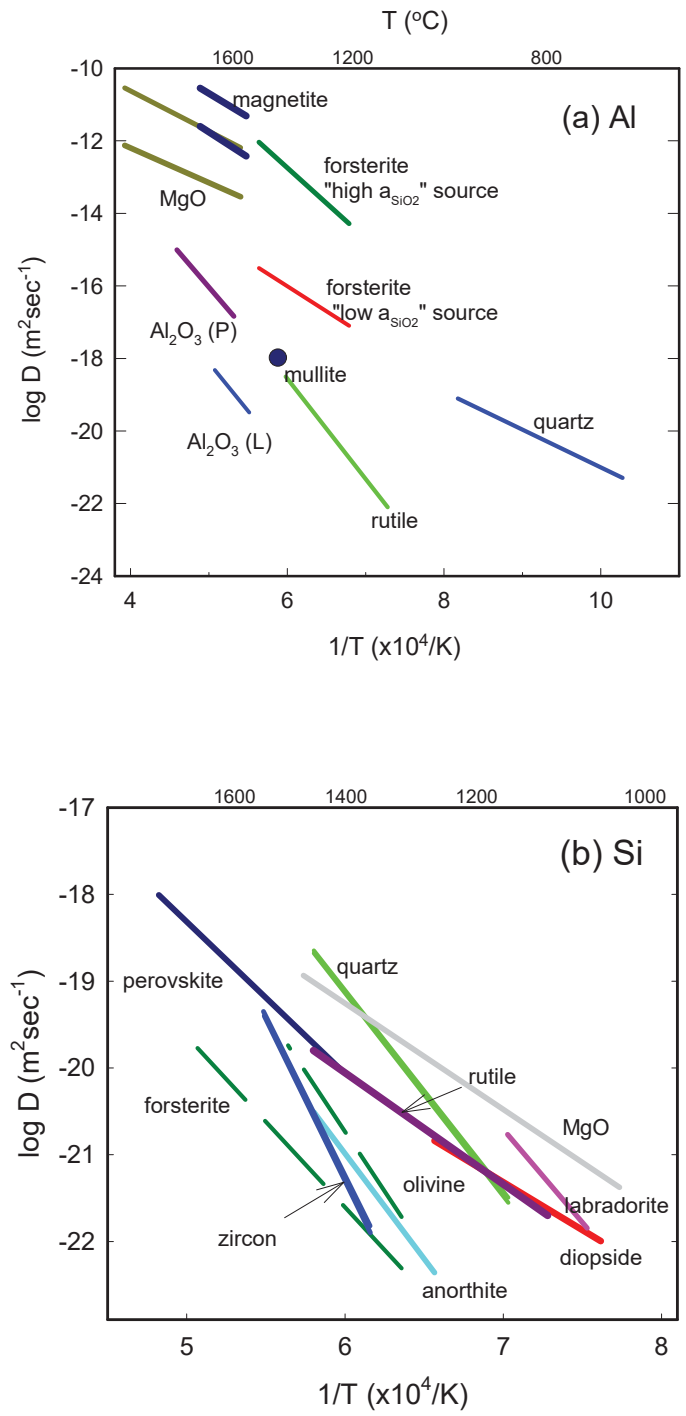


Figure 7

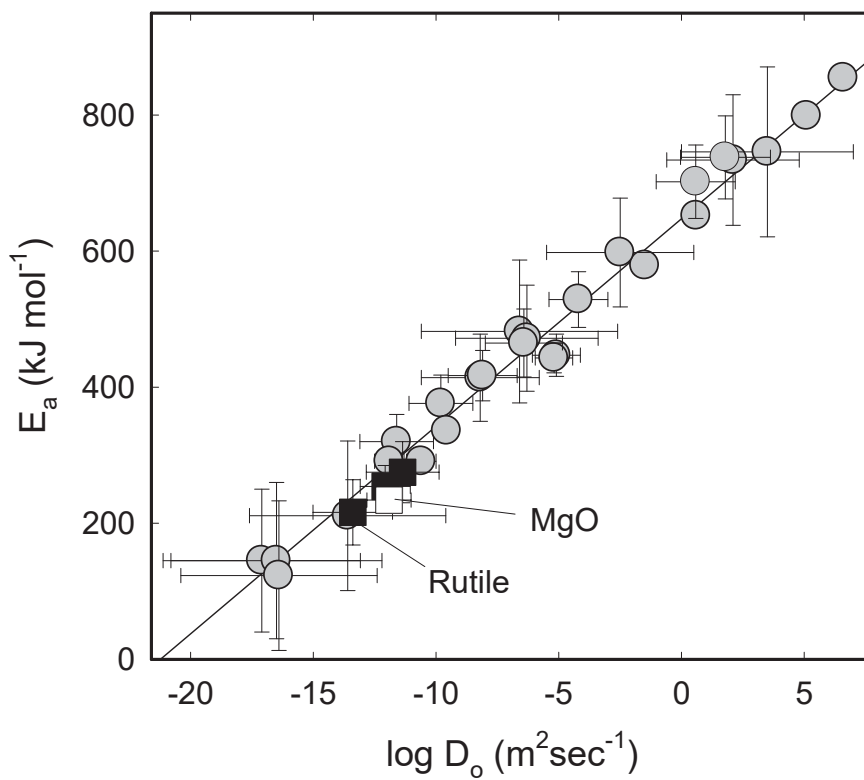


Figure 8

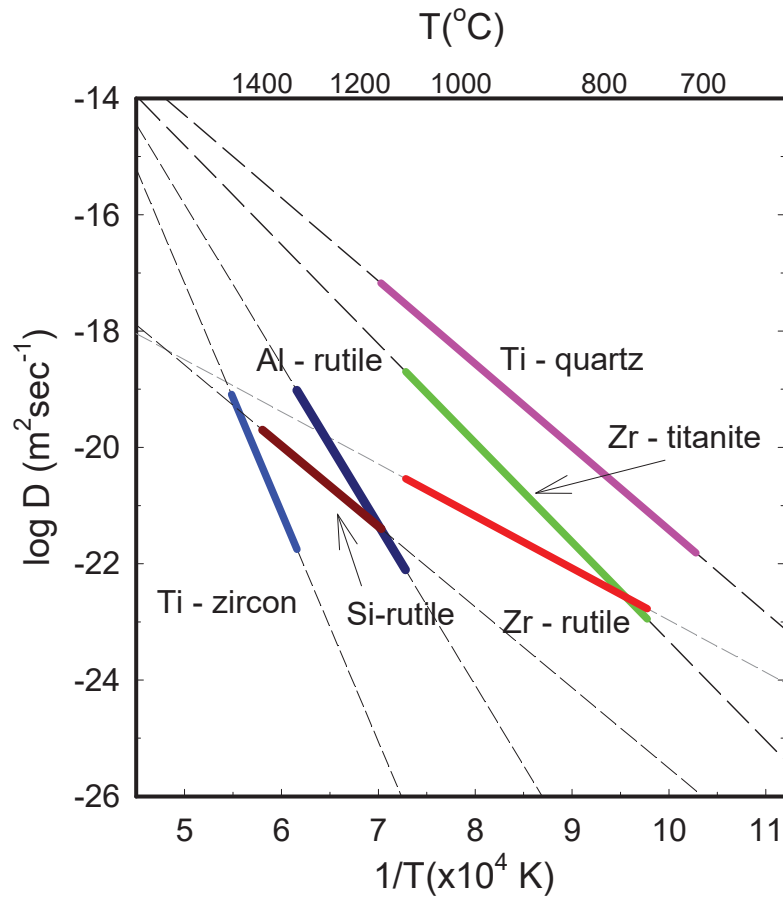


Figure 9

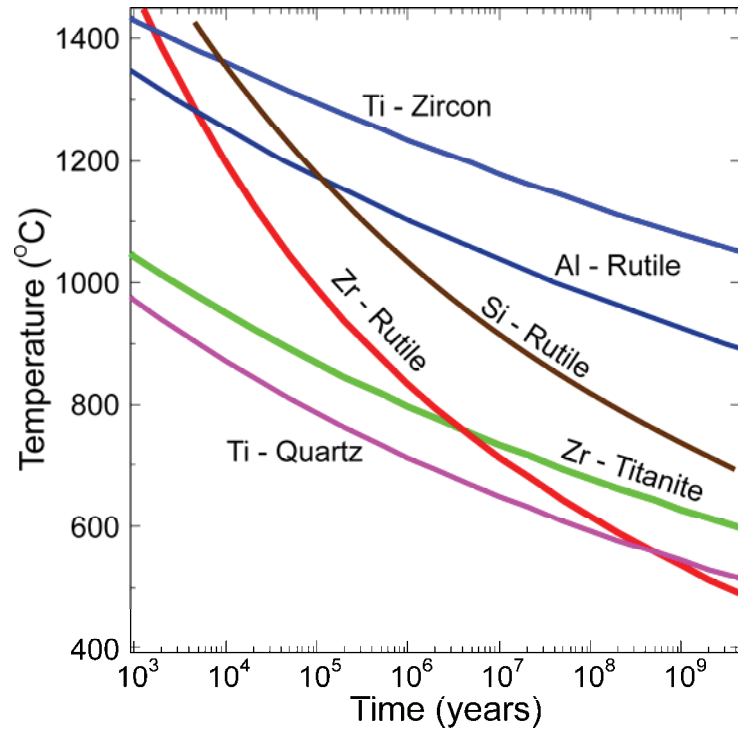


Figure 10

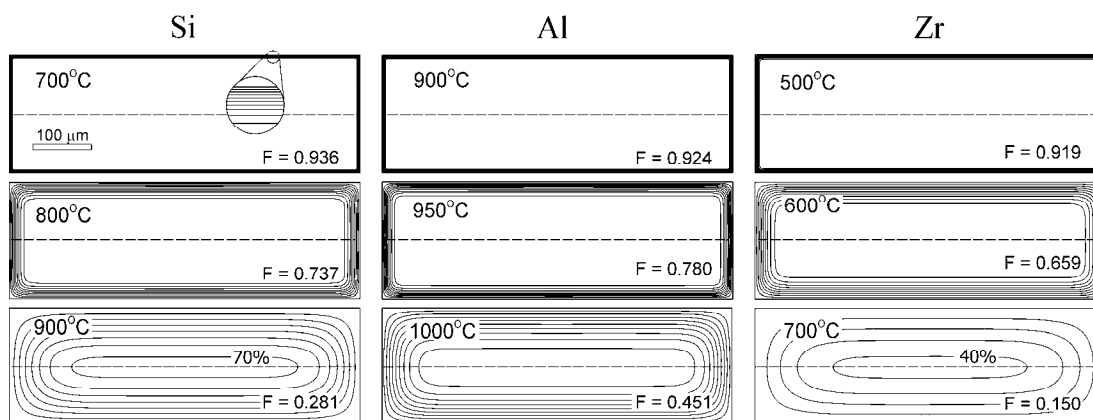


Figure 11

